Application/Control Number: 10/685,251
Art Unit: 1722
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In re application of
Robert J. Falster et al. : DECISION ON
Serial No. 10/685,251 : PETITION
Filed: October 14, 2003
For: PROCESS FOR PRODUCING LOW DEFECT DENSITY SILICON

This is a decision on the REQUEST FOR SUSPENSION UNDER MPEP 709 and 37 CFR 1.103, filed July, 10 2007. The petition requests that a suspension of action be granted since litigation has not-been stayed in the concurrent proceeding before the United States District Court for the Northern District of California, Case NO. C 01-4925 SBA. and the United States District Court for the District of Delaware, Case No. 04-852-SLR pursuant to the requirements of MPEP 709.

Pursuant to applicant's request filed on December 23, 2005, action by the Office is suspended on this application under 37 CFR 1.103(a) for a period of six (6) months. At the end of this period, applicant is required to notify the examiner and request continuance of prosecution or a further suspension. See MPEP § 709.

The petition is GRANTED.

/Michael Barr/
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